IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Yamazaki, et al. Art Unit : 2673

Serial No.: 09/504,235 Examiner: David L. Lewis

Filed : February 15, 2000

Title : METHOD OF MANUFACTURING A SEMICONDUCTOR DEVICE

Commissioner for Patents Washington, D.C. 20231

INFORMATION DISCLOSURE STATEMENT

Dear Sir:

Applicants call attention to the attached Information

Disclosure Statement and documents listed on form PTO-1449. Per

37 CFR 1.98(d), copies of these documents are not provided.

Kindly accept this Information Disclosure Statement under Rule 97(c)(2). The rule 17(p) certification fee of \$180 is enclosed.

Consideration of the foregoing and enclosures plus the return of a copy of the enclosed form PTO-1449 with the Examiner's initials in the left column per MPEP 609 are earnestly solicited along with an early action on the merits.

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Respectfully submitted,

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| - | Substitute Form PTO-1449 U.S. Department of Commerce (Modified) Patent and Trademark Office | | | | |
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| Information Disclosure Statement by Applicant | | | Applicant Yamazaki, et al. | | |
| | (Use several sheets if necessary) | | Filing Date February 15, 2000 | Group Art Unit | _ |

| U.S. Patent Documents | | | | | | | |
|-----------------------|--------------|------------------|---------------|-----------------|-------|----------|----------------------------|
| Examiner Initial | Desig. ID | Patent Number | Issue Date | Patentee | Class | Subclass | Filing Date If Appropriate |
| | AA | 5 569 610 | Oct. 29, 1996 | Zhang et al. | | 0 | |
| | AB | 5 614 733 | Mar 25, 1997 | Zhang et al. | | | |
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| Examiner | Desig. | Document | Publication | Country or | | | Translation | |
| Initial | ID | Number | Date | Patent Office | Class | Subclass | Yes | No |
| | AL | 4-178633 | 6/25/1992 | JР | | | ABSTRACT | |
| | AM | 6-244103 | 9/2/1994 | JР | | | ABSTRACT | |
| | AN | 6-318701 | 11/15/1994 | JР | | | ABSTRACT | |
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| | AP | | | | | | | |

| (| Other Documents (include Author, Title, Date, and Place of Publication) | | | | | |
|------------------|---|----------|--|--|--|--|
| Examiner Initial | Desig. ID | Document | | | | |
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